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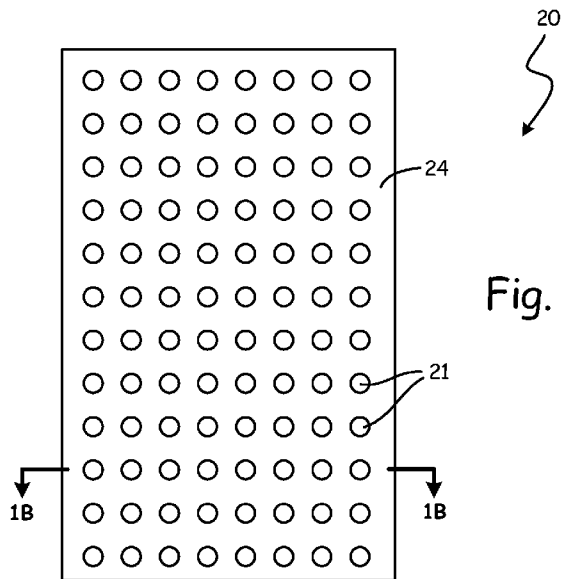


Fig. 1A

(57) Abstract: A method of forming a tape with a matrix of wells includes patterning a first surface of a substrate. The substrate includes the first surface and a planar second surface opposite the first surface. Patterning the first surface of the substrate forms the matrix of wells of the tape. The second surface of the substrate remains planar upon patterning the first surface of the substrate.

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## TAPE WITH A MATRIX OF WELLS

### CROSS-REFERENCE TO RELATED APPLICATION(S)

This application claims priority from U.S. Provisional Application No. 5 61/792,556, filed March 15, 2013 for “ARRAY TAPE FORMATION AND ARRAY TAPE BELT” by Darren Lynn Cook et al.

### BACKGROUND

The present invention relates to inline sample processing on high throughput systems, and more specifically relates to formation of a tape with a matrix of wells and a reusable belt with a matrix of wells. 10

Advances in the biosciences industry have created a demand for high throughput biological sample processing and detection systems. For example, Astle, U.S. Patent No. 6,632,653, discloses a high throughput method of performing biological assays using a tape with a matrix of wells. In a high throughput system, a liquid handling and sample processing system transfers the source and assay from microplates into a tape with a matrix of wells, seals the tape, and accumulates the tape on spools. The tape containing samples, such as biological samples, is then transferred to a water bath product and a reaction may be performed, such as polymerase chain reaction (PCR) using thermocycling. Subsequently, the tape may be loaded onto a detection instrument, which 15 detects presence of a desired analyte, such as nucleic acid presence in a biological sample. 20

Tape with a matrix of wells employed in such high throughput systems is typically used once to process and detect the presence of an analyte in a single sample. After a single use, the tape is discarded. It is not reused due to contamination risks. Additionally, tape with a matrix of wells is typically formed through thermal embossing. 25 Therefore, consumable materials like tape with a matrix of wells increase costs associated with high throughput systems due to the cost of the tape and waste disposal. With a push towards increasing reaction speeds to process even more samples at an even faster rate, tape costs could become prohibitively expensive.

### SUMMARY

A method of forming a tape with a matrix of wells includes patterning a 30 first surface of a substrate. The substrate includes the first surface and a planar second surface opposite the first surface. Patterning the first surface of the substrate forms the matrix of wells of the tape. The second surface of the substrate remains planar upon patterning the first surface of the substrate.

A tape with a matrix of wells includes a substrate with a first surface and a planar second surface opposite the first surface. A matrix of wells is formed on or in the first surface of the substrate.

#### BRIEF DESCRIPTION OF THE DRAWINGS

5           FIG. 1A is a top view of a matrix of wells formed on a substrate using a die cut technique.

          FIG. 1B is a cross-sectional view of a tape with a matrix of wells formed on a substrate using a die cut technique, along line 1B-1B in FIG. 1A.

10          FIG. 2A is a top view of a tape with a matrix of wells formed on a substrate using a laser technique.

          FIG. 2B is a cross-sectional view of a tape with a matrix of wells formed on a substrate using a laser technique, along line 2B-2B in FIG. 2A.

          FIG. 3A is a top view of a tape with a matrix of wells formed on a substrate using a thick film depositing technique.

15          FIG. 3B is a cross-sectional view of a tape with a matrix of wells formed on a substrate using a thick film depositing technique, along line 3B-3B in FIG. 3A.

          FIG. 3C is a cross-sectional view of a tape with a matrix of wells formed on a substrate using a thick film depositing technique.

          FIG. 4A is a top view of a tape with a matrix wells formed on a substrate.

20          FIG. 4B is a cross-sectional view of a tape with a matrix wells formed on a substrate using an additive technique, along line 4B-4B in FIG. 4A.

          FIG. 4C is a cross-sectional view of a tape with a matrix wells formed on a substrate using a subtractive etching technique.

25          FIG. 5 is a schematic diagram of a high throughput system employing a reusable belt with a matrix of wells.

          FIG. 6A is a bottom view of an embodiment of a reusable belt with a matrix of wells on the bottom of the belt.

          FIG. 6B is a cross-sectional view of an embodiment of a reusable belt with a matrix of wells on the bottom of the belt, along line 6B-6B in FIG. 6A.

30          FIG. 7A is a top view of an embodiment of a reusable belt with a matrix of wells on the top of the belt.

          FIG. 7B is a cross-sectional view of an embodiment of a reusable belt with a matrix of wells on the top of the belt, along line 7B-7B in FIG. 7A.

FIG. 8A is a top view of an embodiment of a reusable belt with a matrix of wells on the top of the belt.

FIG. 8B is a cross-sectional view of an embodiment of a reusable belt with a matrix of wells with wells on the top of the belt, along line 8B-8B in FIG. 8A.

5 FIG. 9 is a schematic diagram of another embodiment of a high throughput system employing a reusable belt with a matrix of wells.

FIG. 10 is a schematic diagram of another embodiment of a high throughput system employing a reusable belt with a matrix of wells.

10 FIG. 11 is a schematic diagram of another embodiment of a high throughput system employing a reusable belt with a matrix of wells.

FIG. 12 is a schematic diagram of another embodiment of a high throughput system employing a reusable belt with a matrix of wells.

FIG. 13 is a schematic diagram of another embodiment of a high throughput system employing a reusable belt with a matrix of wells.

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#### DETAILED DESCRIPTION

A system disclosed herein, in one aspect, provides more cost-effective methods of forming disposable tape with a matrix of wells. This provides accurate and controllable methods to introduce wells, recesses, or channels into a substrate to form a  
20 tape with a matrix of wells. Another embodiment replaces disposable tape with a matrix of wells with a reusable belt with a matrix of wells. The reusable belt progresses through a high throughput system for biological sample processing and detection, but is not discarded once detection is complete. Instead, the belt progresses through a decontamination regimen in order to remove processed biological material to allow the belt  
25 to be re-used for biological sample processing and detection. The high throughput system performs inline sampling, where a biological material is dispensed, reagents are added, the samples may be incubated for a specified amount of time to carry out a reaction, and the reaction may be scanned by a detector to determine the amount of an analyte in the biological material.

30 FIGS. 1A and 1B are a top view and a cross-sectional view of tape 20 including matrix of wells 21, substrate 22, and die-cut top layer 24. Matrix of wells 21 is formed on substrate 22 using a die cut technique. Substrate 22 may be a substrate suitable for use as a tape with a matrix of wells. Using die-cut technology, a patterned film is laminated to substrate 22. In an alternative embodiment, hole-punching

technology is used to laminate a patterned film to substrate 22. The attachment of a patterned film to substrate 22 can form matrix of wells 21, resulting in die-cut top layer 24 with a bottom layer of substrate 22. Matrix of wells 20 may be formed in an array pattern on substrate 22. In alternative embodiments, the attachment of a pattern to substrate 22 can form a matrix of recesses, channels, or chambers. In one embodiment, this results in a disposable tape with matrix of wells 21 that can be employed in a high throughput system. The disposable tape with matrix of wells 21 can hold or control fluids or materials deposited into matrix of wells 21 for use, for example, in a bioassay or chemical reaction. A cover layer may be applied to contain fluid or material deposits within matrix of wells 20.

FIGS. 2A and 2B are a top view and a cross-sectional view of tape 25 including matrix of wells 26 and substrate 28. Matrix of wells 26 is formed on substrate 28 using a laser technique. Substrate 28 may be a substrate suitable for use as a tape with a matrix of wells. Using laser technology, such as an excimer laser, matrix of wells 26 is lasered into substrate 28. In an alternative embodiment, a carbon dioxide (CO<sub>2</sub>) laser is used. An excimer laser can controllably and accurately create matrix of wells 26 in substrate 28, allowing for extremely accurate, simple or complex, geometries to be machined into a flat tape format. Matrix of wells 26 may be formed in an array pattern on substrate 28. The size and volume of matrix of wells 26 can be controlled by the amount of material removed by the excimer laser. Additionally, well density can be controlled through use of the laser technique. In alternative embodiments, a matrix of recesses, channels, or chambers can be lasered into substrate 28. In one embodiment, this results in a disposable tape with matrix of wells 26 that can be employed in a high throughput system. The disposable tape with matrix of wells 26 can hold or control fluids or materials deposited into the wells for use, for example, in a bioassay or chemical reaction. A cover layer may be applied to contain fluid or material deposits within matrix of wells 26.

FIGS. 3A-3C are a side view and cross-sectional views of tape 29 including matrix of wells 30, substrate 32, and thick film top layer 34. Matrix of wells 30 is formed on substrate 32 using a thick film depositing technique. Substrate 32 may be a substrate suitable for use as a tape with a matrix of wells. Thick film technology may be used to deposit a thick film layer in a pattern on substrate 32 to form matrix of wells 30 on substrate 32, resulting in thick film top layer 34 with a bottom layer of substrate 32. The pattern may be an array pattern. The bottom of matrix of wells 30 consists of

exposed substrate 32. In alternative embodiments, an array of recesses, channels, or chambers can be formed on substrate 32 by depositing a thick film layer in a desired pattern. In one embodiment, this results in a disposable tape with matrix of wells 30 that can be employed in a high throughput system. The disposable tape with matrix of wells 5 30 can hold or control fluids or materials deposited into matrix of wells 30 for use, for example, in a bioassay or chemical reaction. Cover seal 36 may be applied to contain fluid or material deposits within matrix of wells 30.

FIGS. 4A-4B are a top view and a cross-sectional view of tape 37 including matrix of wells 38, photoresist top layer 40, and substrate 42. Matrix of wells 10 38 is formed on substrate 42 using an additive technique. Substrate 42 may be a substrate suitable for use as a tape with a matrix of wells. Matrix of wells 38 may be formed in an array pattern on substrate 42. A photoresist layer is added to substrate 42 in a pattern to form matrix of wells 38 on substrate 42, resulting in photoresist top layer 40 with a bottom layer of substrate 42. The bottom of matrix of wells 38 consists of exposed 15 substrate 42. In an alternative embodiment shown in a cross-sectional view in FIG. 4C, tape 43 includes matrix of wells 44 and substrate 46. Matrix of wells 44 may be etched into substrate 46 using a subtractive technique such as photochemical etching, plasma etching, vapor etching, particle etching, or any other suitable etching technique. Matrix of wells 44 may be etched in an array on substrate 46.

Etching may controllably and accurately create wells in substrates, 20 allowing for extremely accurate, simple or complex, geometries to be machined into a flat tape format. The size and volume of the wells can be controlled by the amount of material removed by etching. Additionally, well density may be controlled. In alternative embodiments, an array of recesses, channels, or chambers can be formed. In one embodiment, this results in tape 37 with matrix of wells 38 or tape 43 matrix of wells 25 44 that may be employed in a high throughput system. Tape 37 or tape 43 may hold or control fluids or materials deposited into the wells for use, for example, in a bioassay or chemical reaction. A cover seal may be applied to contain fluid or material deposits within matrix of wells 38 or matrix of wells 44.

In an alternative embodiment to the techniques described in FIGS. 1-4, a 30 mechanical embossing technique may be used to emboss dimples into a substrate and displace the substrate material into the surrounding area. This mechanical embossing could be performed using a stamping technique or any other suitable mechanical technique. Mechanical embossing may produce arrays of wells with a range of volumes.

For example, small dimples may be produced for reactions encased in oil that require very low sample volumes.

In an alternative embodiment, instead of forming wells, a secondary substrate or coating could be applied to a base substrate using any appropriate technique such that the substrate or coating is capable of capturing samples and reagents. The  
5 substrate or coating may, for example, be paper, fabric, or a gel such as a hydrogel or agarose gel. Samples may be added in specific locations on the substrate. The substrate could be preloaded with reagents for a desired chemical reaction and the sample can subsequently be added to the substrate. Alternatively, the substrate may be preloaded  
10 with a sample and reagents subsequently added to the substrate.

All of the above techniques can produce a tape with a matrix of wells with a flat bottom. The substrate may be plastic, metal, ceramic, glass, or any other suitable substrate for the appropriate technique. If a cover seal is applied, the tape with a matrix of wells will include both a flat top and a flat bottom. This is advantageous over  
15 traditional tape with a matrix of wells, which does not have a flat bottom due to thermoformed wells. A flat top and flat bottom allow imaging techniques for detecting a desired analyte, for example, to be used via either the cover seal or through the bottom layer of the tape with a matrix of wells or both. In some embodiments, magnets, heaters, coolers, vibrations, or other interactive systems may be applied directly to the flat  
20 surfaces of either or both the cover seal and the bottom layer of the tape with a matrix of wells to manipulate the fluids or materials deposited in the tape with a matrix of wells. In other embodiments, either or both the cover seal and the bottom layer of the tape with a matrix of wells may be imparted with a coating or finish that is metallic, dielectric, refractive, reflective, or absorbent.

The well formation techniques can accurately produce wells that  
25 accommodate very low volumes of fluids and particles, such as wells for microfluidic applications. The techniques minimally affect the material chemical properties of substrate materials. Furthermore, these techniques are fast, low cost, and allow flexibility in manufacturing. These techniques may be used to create different formats for the tape  
30 with a matrix of wells such as individual arrays, continuous carrier tape including arrays used in a reel-to-reel process, microplate arrays, or slide arrays. The techniques described may also be used to create a matrix of wells on the second aspect of the system disclosed herein, which is a reusable belt with a matrix of wells.

FIG. 5 is a schematic diagram of high throughput system 50 employing reusable belt 52. Reusable belt 52 is a continuous loop/belt of tape with a built-in matrix of reaction wells. Reusable belt 52 can be utilized to process a sample, such as a biological sample, in a high throughput system and subsequently be decontaminated and reused to process a new sample. High throughput system 50 includes reusable belt 52, dispensing station 54, detection station 56, and wash/decontamination station 58. Wash/decontamination station 58 may include wash step 60, vacuum step 62, decontamination step 64, and drying step 66. Wash/decontamination station 58 eliminates the need for disposing of tape due to contamination risks, and allows reusable belt 52 to be used for processing numerous biological samples. Wash/decontamination station 58 provides a tightly controlled environment to control waste products such as amplicons from contaminating other parts of the high throughput system and subsequent samples. In one embodiment, wash/decontamination station 58 may be contained within a separate, sealed chamber. In an alternative embodiment, negative pressure could be used within a separate, sealed chamber to inhibit the possible escape of biological material from wash/decontamination station 58.

A biological sample may be loaded into the matrix of wells of reusable belt 52 and any necessary reagents for a desired reaction may be loaded into the matrix of wells of the reusable belt 52 at dispensing station 54. A reaction can subsequently take place and reusable belt 52 may proceed to detection station 56 where a desired analyte can be detected. Once the detection is complete, reusable belt 52 proceeds to wash/decontamination station 58. The first step in wash/decontamination station 58 is to remove the completed reaction by washing out the matrix of wells of reusable belt 52 in wash step 60 and/or applying a vacuum in vacuum step 62. In an alternative embodiment an air knife or a water knife may be used. In other embodiments, any combination of a wash, a vacuum, an air knife, and a water knife may be used. The reaction wells are systematically washed depending on how the biological sample is processed within high throughput system 50, including DNA amplification, RNA amplification, protein detection, and small molecule detection.

After the bulk reaction is removed, reusable belt 52 moves to more refined decontamination step 64, where decontamination and/or sterilization is performed to ensure that DNA/RNA/protein products are completely removed from the reaction wells of reusable belt 52. Biological products may be removed using chemical solutions like bleach, acid, or any other suitable chemical agent. In alternative embodiments, UV



radiation, heat, or cold may be used to remove the biological products. In an alternative embodiment, a chlorine solution may be sprayed in or fogged in, or the reaction wells may be immersed in a chlorine solution. After decontamination step 64 is complete, reusable belt 52 proceeds to drying step 66 where the reaction wells of reusable belt 52 are dried to make sure there is no residual decontamination material in the wells that would inhibit reactions of new samples. Since reusable belt 52 is a continuous loop with reaction wells built in, while some wells are decontaminated in wash/decontamination station 58, decontaminated wells could proceed through the rest of high throughput system 50 to simultaneously process another biological sample.

As stated above, the reaction wells in reusable belt 52 may be formed by using any of the techniques referred to in relation to FIGS. 1-4. Reusable belt 52 may be made of stainless steel or any other suitable metal, which is resilient to rust and degradation. In an alternative embodiment, reusable belt 52 may be made of a material similar to disposable tape with a matrix of wells, such as a polymer. In other embodiments, reusable belt 52 may be made of any other suitable material that can operate in a flexible manner and cycle within high throughput system 50. The format of the reaction wells of reusable belt 52 may be a traditional rectangular array, a radial array, a single well row, or any other matrix format suitable for processing a desired biological material sample. Additionally, reusable belt 52 may be continuous or may be segmented, similar to a bulldozer track. In alternative embodiments, reusable belt 52 may be made of discrete films that are somewhat connected. In other embodiments, reusable belt 52 may be made of array segments that are held together, for example, by a magnet, strapped together, or riveted together.

FIGS. 6A and 6B are a bottom view and a cross-sectional view of an embodiment of reusable belt 52 with matrix of wells 68 with matrix of wells 68 formed on the bottom of reusable belt 52. Matrix of wells 68 may be formed in an array pattern on reusable belt 52. Reusable belt 52 may be transparent such that each of the wells of matrix of wells 68 is visible from the top of reusable belt 52. With matrix of wells 68 on the bottom of reusable belt 52, a reagent can be dispensed from the bottom of reusable belt 52, as shown in FIG. 5. Depending on the reaction taking place in the high throughput system, detection may occur from the bottom or the top of this embodiment of reusable belt 52.

FIGS. 7A and 7B are a top view and a cross-sectional view of another embodiment of reusable belt 52 with matrix of wells 68 formed on the top of reusable belt

52. Matrix of wells 68 may be formed in an array pattern on reusable belt 52. The bottom of reusable belt 52 is flat, thus detection can occur from either the top of reusable belt 52 or the bottom of reusable belt 52.

FIGS. 8A and 8B are a top view and a cross-sectional view of another embodiment of reusable belt 52. Reusable belt 52 includes arrays 70 with matrix of wells 68 and belt portion 72. Belt portion 72 of reusable belt 52 may be made of stainless steel containing gaps or windows. Arrays 70 are configured to be placed over the gaps or windows in reusable belt 52. Arrays 70 may be made of a transparent material such that detection may occur from underneath reusable belt 52.

FIG. 9 is a schematic diagram of high throughput system 80 employing reusable belt 82. High throughput system 80 includes top dispensing station 84, detection station 86, and wash/decontamination station 88. High throughput system 80 also allows simultaneous reaction incubation and detection for processes such as real time polymerase chain reaction and isothermal polymerase chain reaction. Since reusable belt 82 is a continuous loop with reaction wells built in, while some wells are decontaminated in wash/decontamination station 88, decontaminated wells could simultaneously proceed through the rest of high throughput system 80 to process another biological sample.

FIG. 10 is a schematic diagram of high throughput system 90 employing reusable belt 92. High throughput system 90 includes bottom dispensing station 94, detection station 96, and wash/decontamination station 98. Wash/decontamination station 98 of this embodiment includes a wash basin to decontaminate the reaction wells of reusable belt 92.

FIG. 11 is a schematic diagram of high throughput system 100 employing reusable belt 102. High throughput system 100 includes dispensing station 104, detection station 106, belt cleaning station 108, cover seal belt 110, and cover seal belt cleaning station 112. A biological sample may be loaded into reusable belt 102 of high throughput system 100 and a reagent may be dispensed at dispensing station 104. Subsequently, a cover seal may be placed from cover seal belt 110 onto reusable belt 102, covering the reaction wells of reusable belt 102. Reusable belt 102 then proceeds to detection station 106, where detection of a desired analyte occurs. The cover seal is then removed by cover seal belt 110, and cover seal belt 110 continues to cover seal belt cleaning station 112. Reusable belt 102 proceeds to belt cleaning station 108. Thus, both cover seal belt 110 and reusable belt 102 are cleaned and decontaminated and may be reused in high throughput 100 system to process additional biological samples.

FIG. 12 is a schematic diagram of high throughput system 120 employing reusable belt 122. High throughput system 120 includes two dispensing stations 124, detection station 126, belt cleaning station 128, cover seal dispensing station 130, cover seal removal station 132, and incubation station 134. High throughput system 120 does not use a reusable cover seal. Instead, a sample may be loaded or dispensed into reusable belt 122, one or more reagents may be dispensed in one or more of dispensing stations 124, a cover seal may be placed over reusable belt 122 by cover seal dispensing system 120, and reusable belt 122 may proceed through high throughput system 120. Incubation station 134 allows reusable belt 122 to accumulate, incubate at a constant temperature, or pass through to detection station 136 if incubation is unnecessary for the desired reaction to take place.

After reusable belt 122 passes through detection station 126 and the biological sample analysis is complete, the cover seal is removed by cover seal removal station 132 and the used cover seal is taken up by a cover seal take up. The used cover seal is subsequently disposed. Reusable belt 122 proceeds to belt cleaning station 128, where reusable belt 122 is washed and/or decontaminated and may subsequently be reused in high throughput system 120 to process additional biological samples.

FIG. 13 is a schematic diagram of high throughput system 140 employing reusable belt 142. High throughput system 140 includes three dispensing stations 144, detection station 146, belt cleaning station 148, two cover seal dispensing stations 150, two cover seal removal stations 152, and incubation station 154. A sample may be loaded or dispensed into reusable belt 142, one or more reagents may be dispensed in one or more of the first two dispensing stations 144, a cover seal may be placed over reusable belt 142 by the first cover seal dispensing station 150, and reusable belt 142 may proceed through high throughput system 140. Incubation station 154 reusable belt 142 to accumulate, incubate at a constant temperature, or pass through to the third dispensing station 144 or detection station 146 if incubation is unnecessary for the desired reaction to take place.

The cover seal may subsequently be removed at the first cover seal removal station 150 and reusable belt 142 may proceed to the third dispensing station 144, where additional reagents may be added to the reaction wells. The reaction may be resealed at the second cover seal dispensing station 150, and reusable belt 142 may proceed to detection station 146. After detection, the second cover seal may be removed, taken up, and subsequently disposed at the second cover seal removal station 152.

Reusable belt 142 proceeds to belt cleaning station 148, where reusable belt 142 is washed and decontaminated and may subsequently be reused in high throughput system 140 to process additional biological samples.

Although the present invention has been described with reference to preferred  
5 embodiments, workers skilled in the art will recognize that changes may be made in form  
and detail without departing from the spirit and scope of the invention.

## CLAIMS:

1. A method of forming a tape with a matrix of wells, the method comprising:  
patterning a first surface of a substrate, the substrate including the first surface and  
5 a planar second surface opposite the first surface;  
wherein patterning the first surface of the substrate forms the matrix of wells of  
the tape; and  
wherein the second surface of the substrate remains planar upon patterning the  
first surface of the substrate.
- 10 2. The method of claim 1, wherein patterning the first surface of the substrate  
includes laminating a patterned film layer to the first surface of the substrate layer using a  
die-cut technique or a hole-punching technique.
3. The method of claim 1, wherein patterning the first surface of the substrate  
includes depositing a thick film layer on the first surface of the substrate layer using a  
15 thick film depositing technique.
4. The method of claim 1, wherein patterning the first surface of the substrate  
includes adding a patterned photoresist layer to the first surface of the substrate using an  
additive technique.
5. The method of claim 1, wherein patterning the first surface of the substrate  
20 includes selectively removing the substrate from the first surface of the substrate using a  
carbon dioxide laser or an excimer laser.
6. The method of claim 1, wherein patterning the first surface of the substrate  
includes selectively removing the substrate from the first surface of the substrate using a  
subtractive etching technique.
- 25 7. The method of claim 6, wherein the subtractive etching technique is  
photochemical etching, plasma etching, vapor etching, or particle etching.
8. The method of claim 1, wherein patterning the first surface of the substrate  
includes selectively displacing the substrate from the first surface of the substrate using a  
mechanical embossing technique.
- 30 9. A tape with a matrix of wells, the tape comprising:  
a substrate comprising:  
a first surface; and  
a planar second surface opposite the first surface; and  
a matrix of wells formed on or in the first surface of the substrate.

10. The tape of claim 9, wherein the matrix of wells is formed by a patterned film layer laminated to the first surface of the substrate using a die-cut technique or a hole-punching technique.
11. The tape of claim 9, wherein the matrix of wells is formed by a thick film layer deposited on the first surface of the substrate using a thick film depositing technique.
12. The tape of claim 9, wherein the matrix of wells is formed by a patterned photoresist layer added to the first surface of the substrate using an additive technique.
13. The tape of claim 9, wherein the matrix of wells is formed by selectively removing the substrate from the first surface of the substrate using a carbon dioxide laser or an excimer laser.
14. The tape of claim 9, wherein the matrix of wells is formed by selectively removing the substrate from the first surface of the substrate using a subtractive etching technique.
15. The tape of claim 9, wherein the matrix of wells layer is formed by selectively displacing the substrate from the first surface of the substrate using a mechanical embossing technique.
16. The tape of claim 9, wherein the substrate comprises plastic, metal, ceramic, or glass.
17. The tape of claim 9, and further comprising a cover seal.

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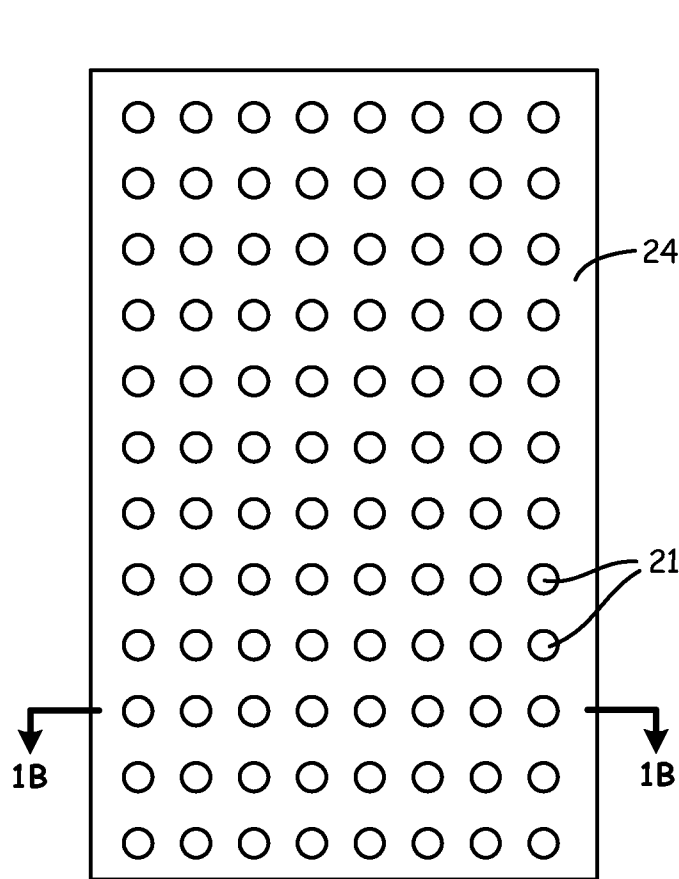


Fig. 1A

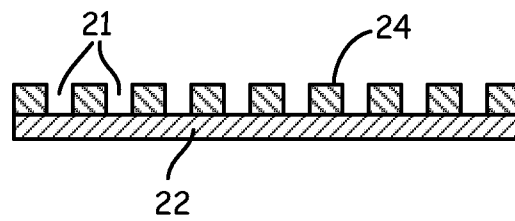


Fig. 1B

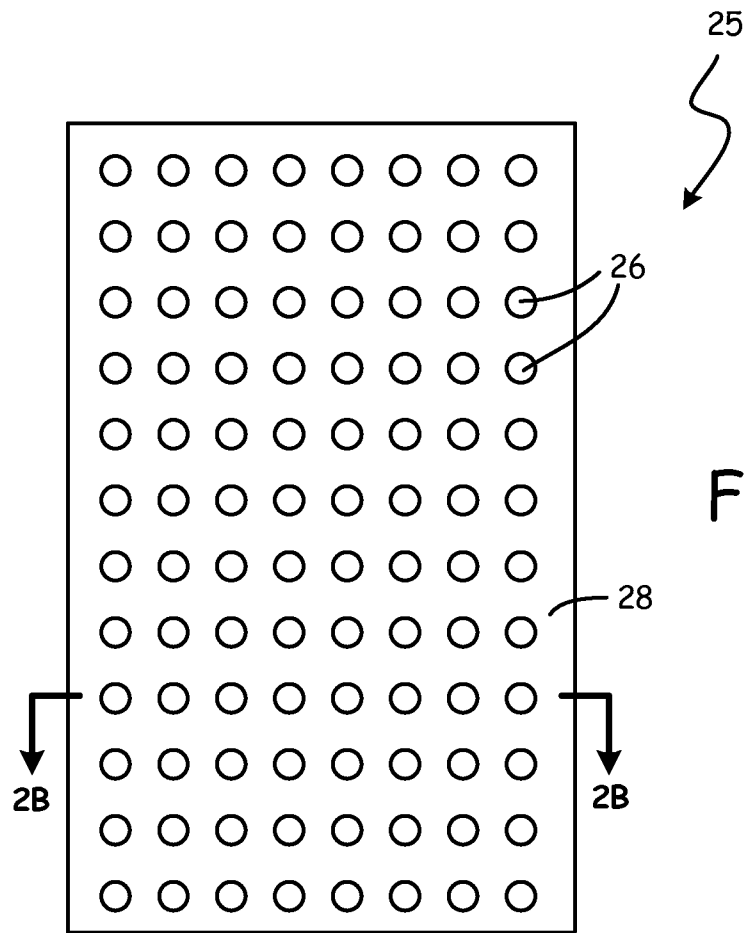


Fig. 2A

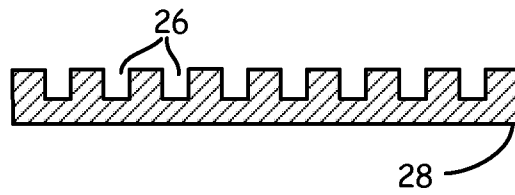


Fig. 2B



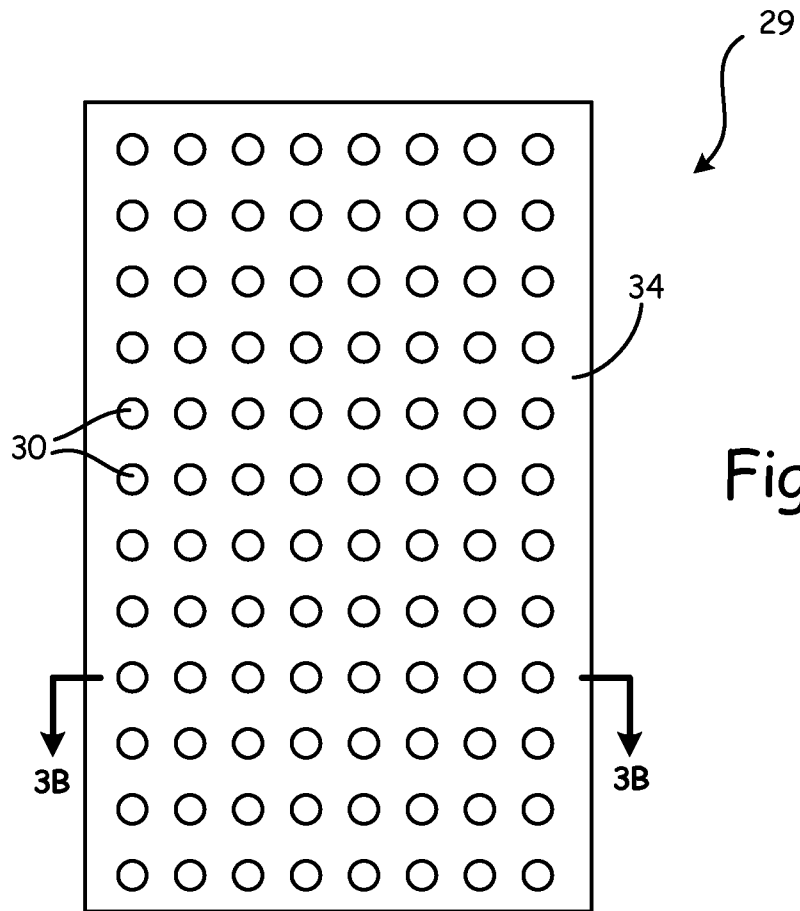


Fig. 3A

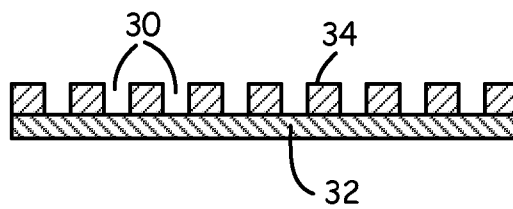


Fig. 3B

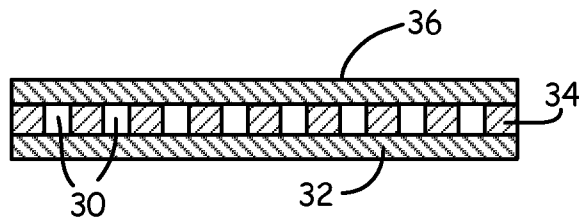


Fig. 3C

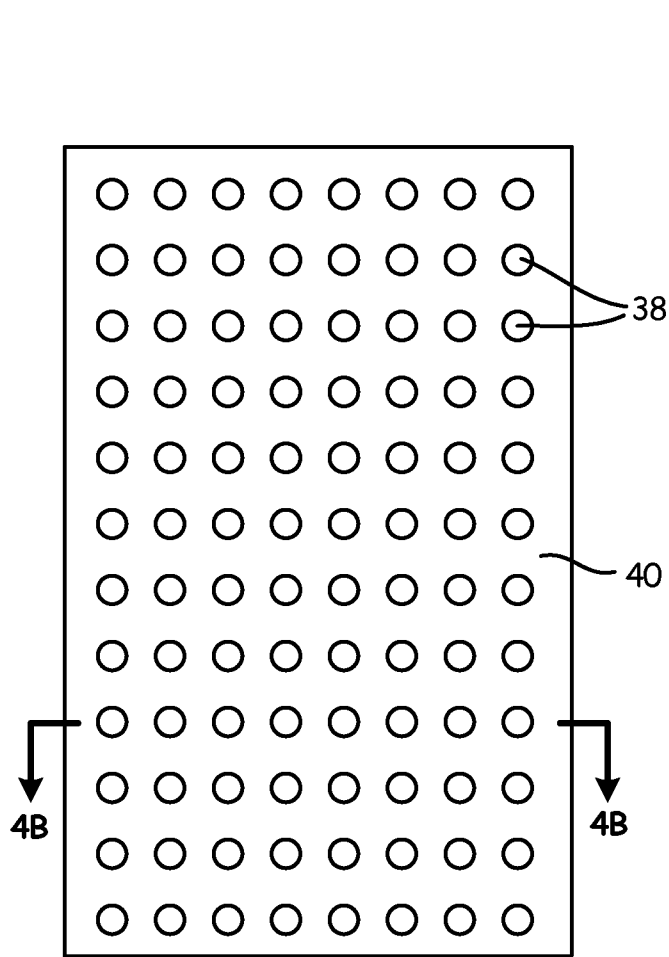


Fig. 4A

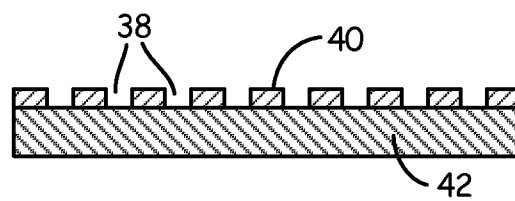


Fig. 4B

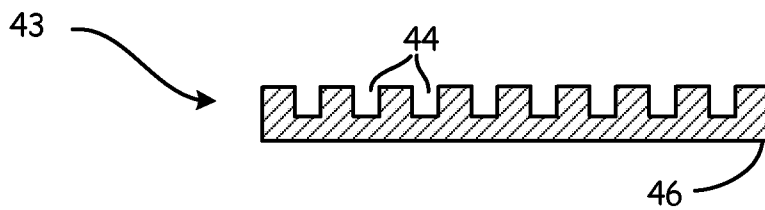


Fig. 4C

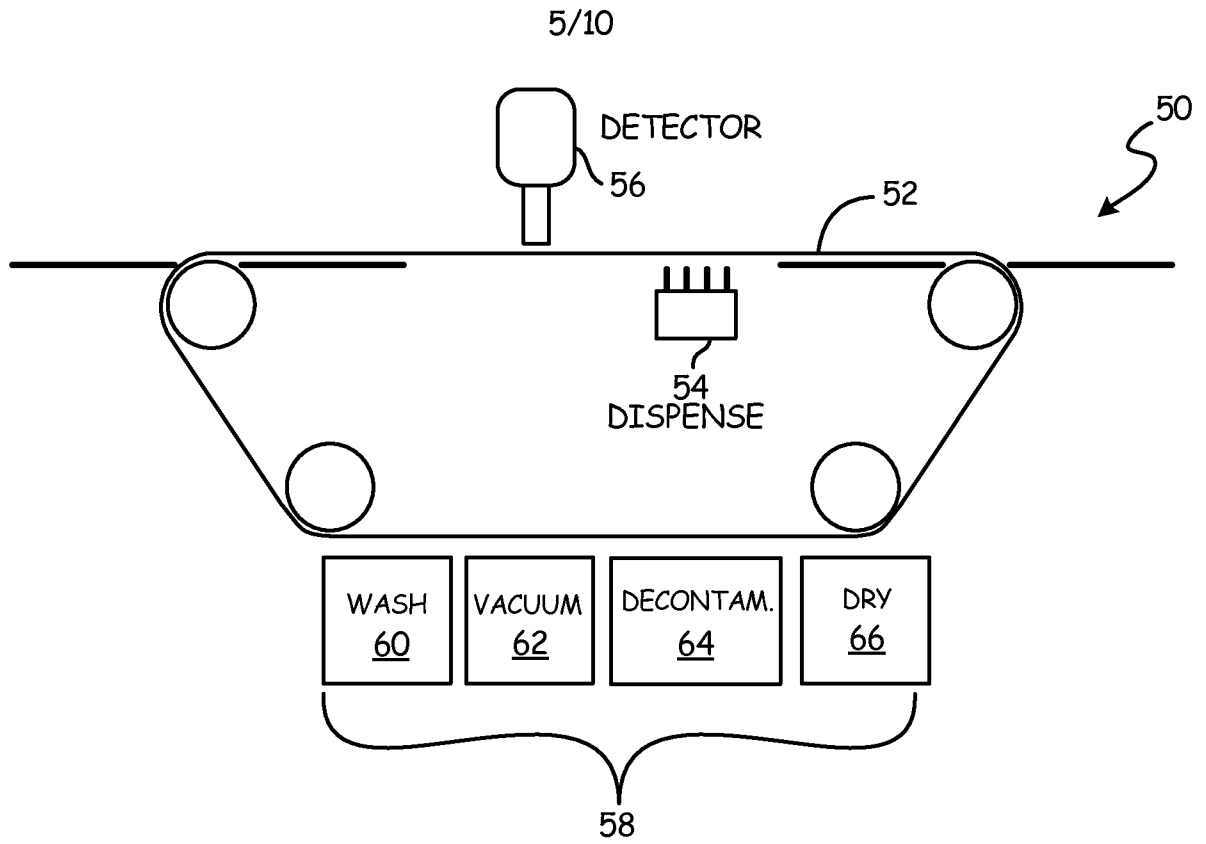


Fig. 5

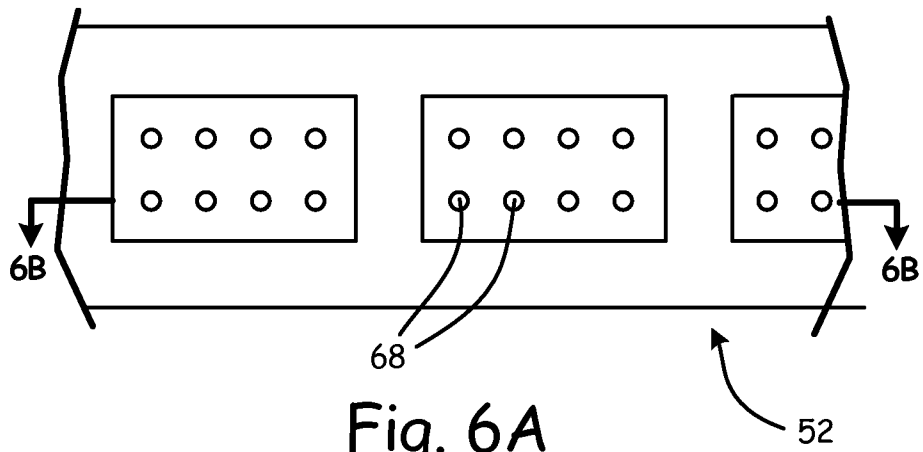


Fig. 6A

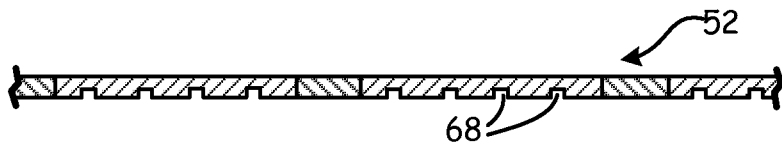


Fig. 6B

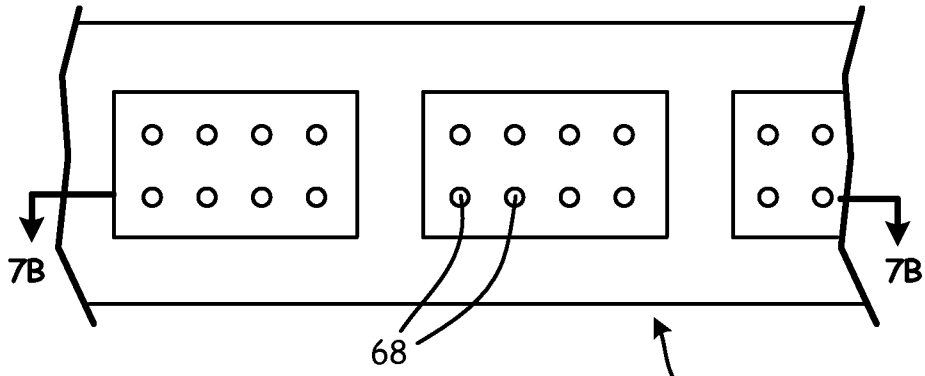


Fig. 7A

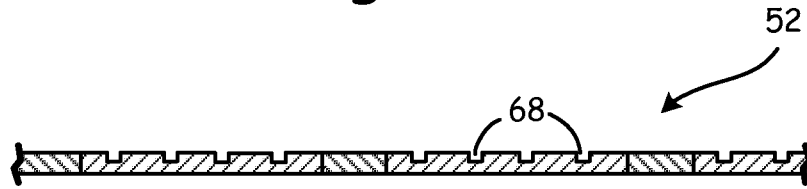


Fig. 7B

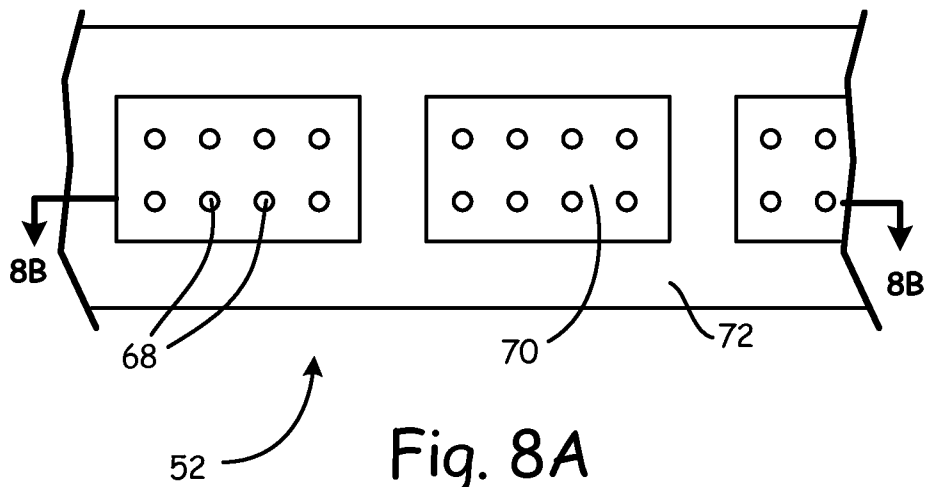


Fig. 8A

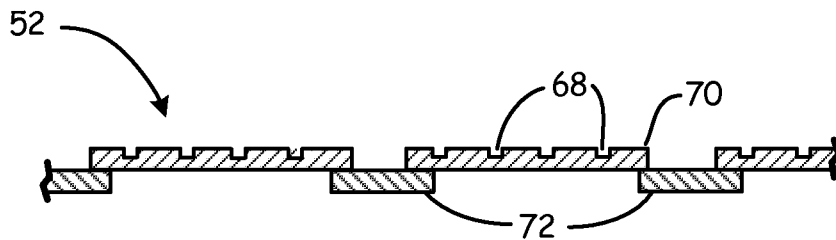


Fig. 8B

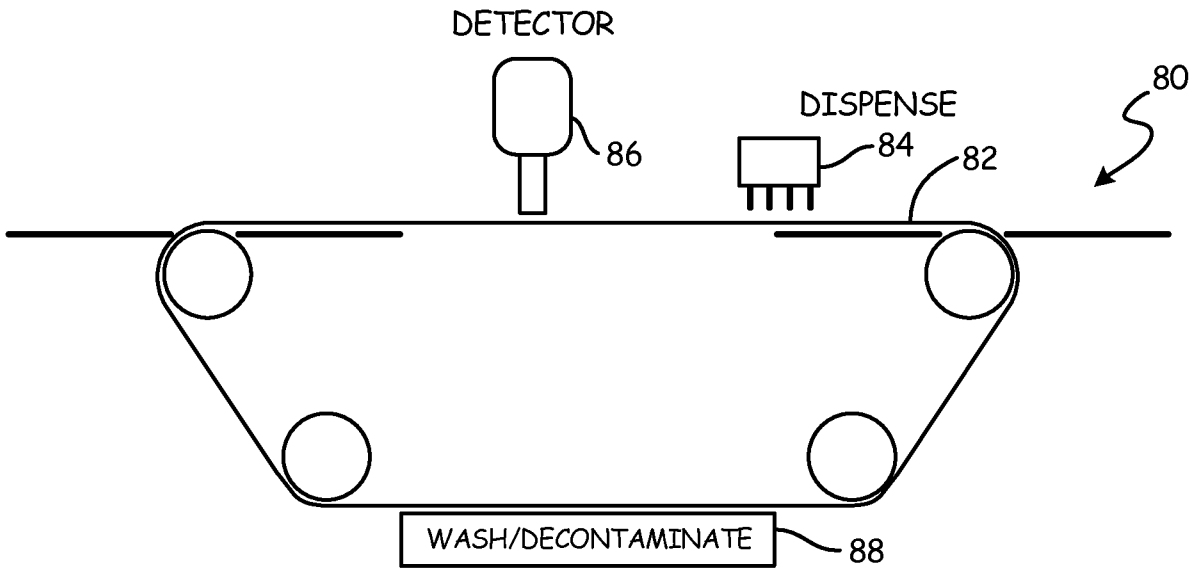


Fig. 9

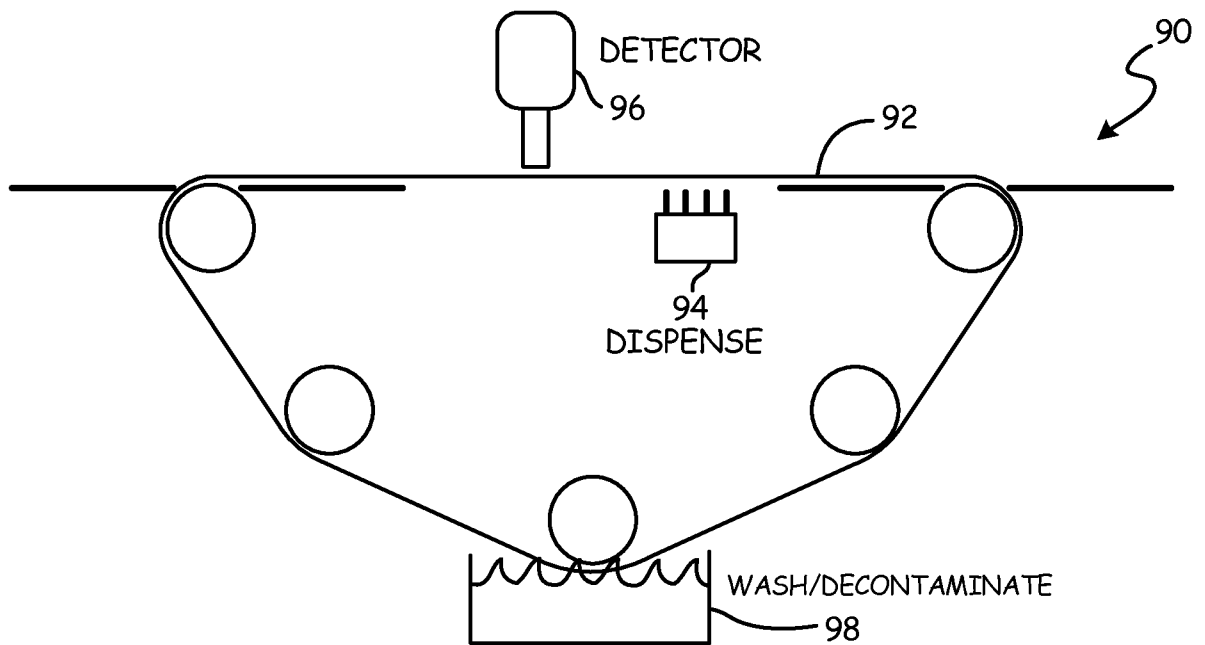


Fig. 10

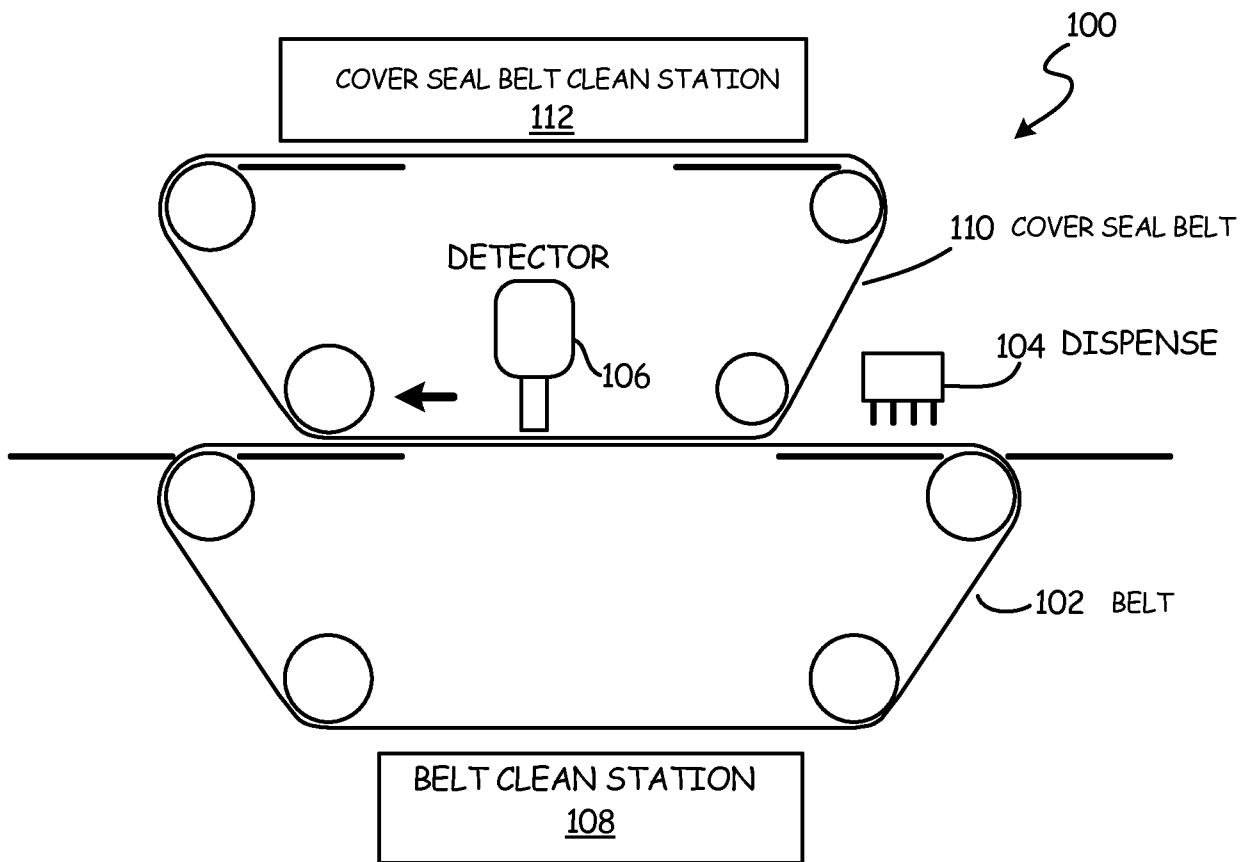


Fig. 11

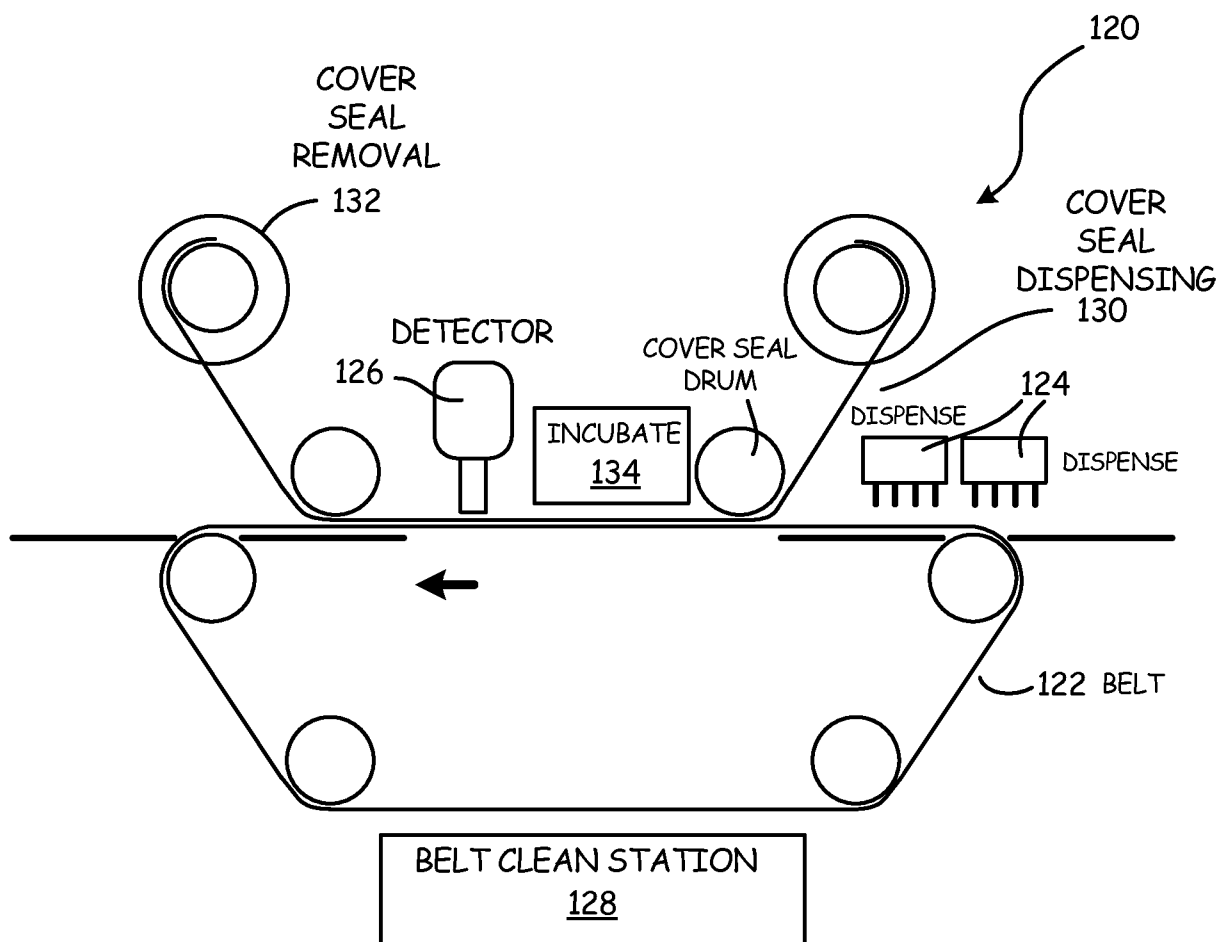


Fig. 12

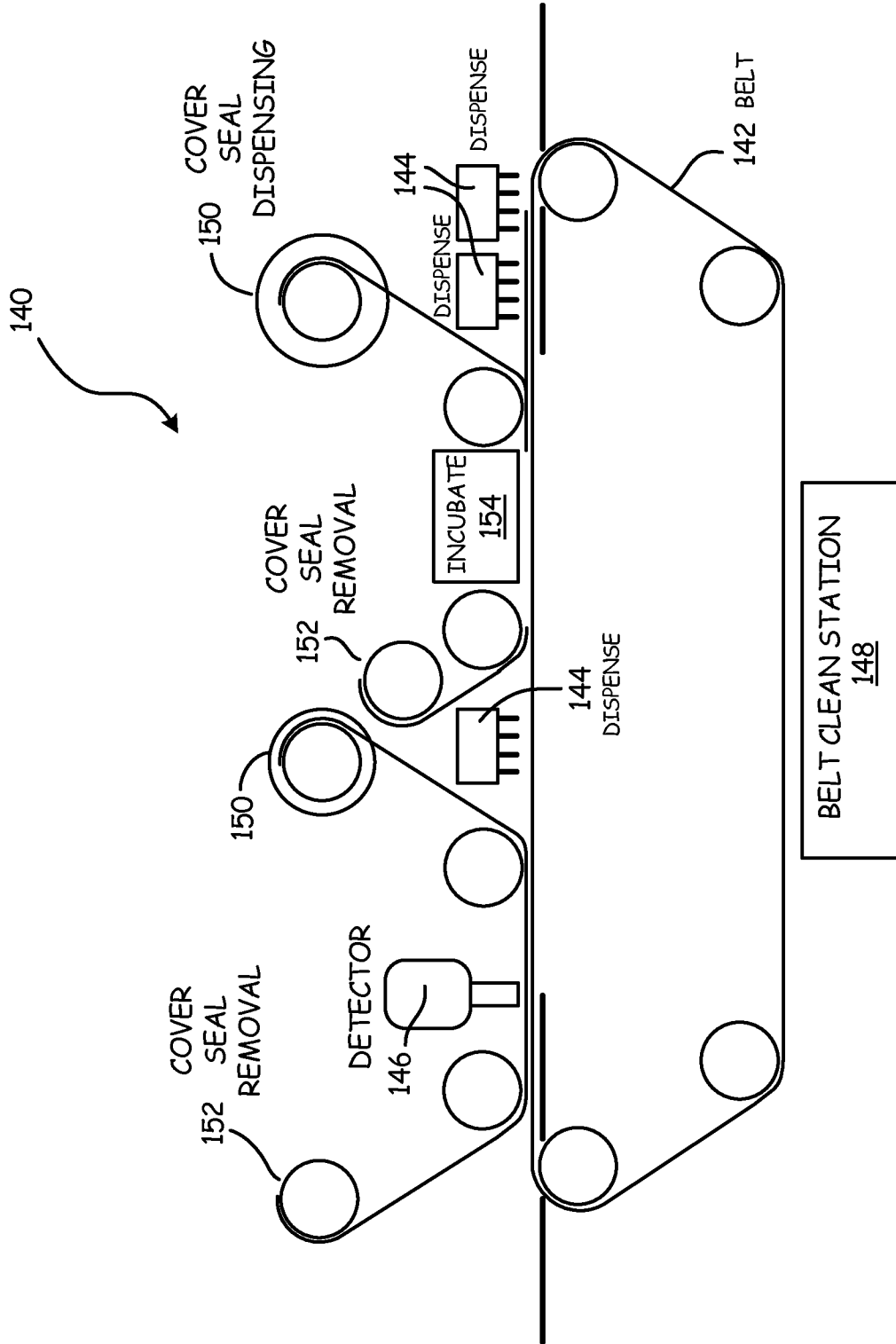


Fig. 13



**INTERNATIONAL SEARCH REPORT**

International application No.

PCT/US14/28415

**A. CLASSIFICATION OF SUBJECT MATTER**

IPC(8) - B32B 37/02, 37/04, 37/10 (2014.01)

USPC - 422/552, 553; 506/8

According to International Patent Classification (IPC) or to both national classification and IPC

**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

IPC(8): B01L 3/00; B29C 59/00; B32B 37/02, 37/04, 37/10, 37/12, 37/16, 37/30, 38/04, 38/06, 38/10, 38/14 (2014.01)

USPC: 422/66, 407, 552, 553; 156/423; 506/8, 13; 435/4

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

MicroPatent (US-G, US-A, EP-A, EP-B, WO, JP-bib, DE-C,B, DE-A, DE-T, DE-U, GB-A, FR-A); Google Scholar; ProQuest; IP.com; ablation, array, diecut, emboss, etch, excimer, laser, layer, matrix, microplate, microwell, pattern, punch, tape, thick film, wells

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2012/0247642 A1 (BARTHOLOMEUSZ, DA et al.) 04 October 2012; figures 8, 19; paragraphs [0058], [0064], [0076]-[0077]	1-2, 9-10
X --- Y	US 2005/0153102 A1 (MAZUREK, MH et al.) 14 July 2005; figures 1, 7-8; paragraphs [0012]-[0016], [0084], [0104], [0116], [0122]	1, 8-9, 15-16 ----- 3-7, 11-14
X	US 2012/0230892 A1 (PETERSON, KA et al.) 13 September 2012; figures 1, 2a-c; paragraphs [0054], [0063]	9, 17
Y	US 2003/0190608 A1 (BLACKBURN, G) 09 October 2003; figure 14A; paragraphs [0068], [0120]-[0128]	3-4, 11-12
Y	US 2005/0191663 A1 (BEATTIE, KL) 01 September 2005; figure 1; paragraphs [0080], [0093]-[0095]	5, 13
Y	US 2011/0006674 A1 (NAAMAN, R et al.) 13 January 2011; figure 1; paragraphs [0049]-[0052]	6-7, 14
A	US 2008/0132426 A1 (HART, MW et al.) 05 June 2008; entire document	1-17
A	US 2011/0045248 A1 (HOFFMULLER, W et al.) 24 February 2011; entire document	1-17
A	US 2011/0195496 A1 (MURAGUCHI, A et al.) 11 August 2011; entire document	1-17
A	US 2004/0242023 A1 (YAN, M et al.) 02 December 2004; entire document	1-17

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"E" earlier application or patent but published on or after the international filing date	"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	"&" document member of the same patent family
"O" document referring to an oral disclosure, use, exhibition or other means	
"P" document published prior to the international filing date but later than the priority date claimed	

Date of the actual completion of the international search

09 JULY 2014 (09.07.2014)

Date of mailing of the international search report

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